

r'64	Subclass	ISSUE CLASSIFICATION
252	Class	ISSUE CLA

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	PATENT NUMBER	l
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U.S. **UTILITY** Patent Application

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O.I.P.E.	PATENT DATE	
SCANNED TO G.A. AA		

APPLICATION NO. CONT/PRIOR CLASS SUBCLASS ART UNIT EXAMINER

09/842476 D 252 79.1 1765 Umc7-EMAINS

2 Vuchun Wans

Vuchun ahng, majery Baja, Fred Redeker Shijian Li

Chemical mechanical polishing composition and process

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PTO-2040 12/99

ISSUING CLASSIFICATION							
ORIGINA	L		CROSS REFERENCE(S)				
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)				
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INTERNATIONAL	CLASSIFICATION	1438	(e 4-2::-				
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TERMINAL	DRAWINGS			CLAIMS ALLOWED		
L DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.	
The term of this patent subsequent to(date) has been disclaimed.	Lyneste T. Uw (Assistant B	Eze Eronia	i 4/14 03	NOTICE OF ALLOWANCE MAILED		
The term of this patent shall not extend beyond the expiration date of U.S Patent. No.				ISSUE FEE		
				Amount Due	Date Paid	
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The terminalmonths of this patent have been disclaimed.				ISSUE BA	TCH NUMBER	
	(Legal Instrume	nts Examiner)	(Date)			
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om PTO-436A Rev. 6/99)			FILED WITH:	DISK (CRF)	FICHE CD-RO	